



Form PTO-1449

LIST OF PATENTS AND PUBLICATIONS FOR  
APPLICANT'S INFORMATION DISCLOSURE  
STATEMENT

(Use several sheets if necessary)

ATTORNEY DOCKET NO.  
10030753SERIAL NO.  
10/765647

APPLICANT

Laura Wills Mirkarimi

FILING DATE  
January 26, 2004GROUP  
1765

## REFERENCE DESIGNATION

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME

## FOREIGN PATENT DOCUMENT

	DOCUMENT NUMBER	DATE	NAME	TRANSLATION YES NO
/DD/	1 528 592 A2	05/04/2005	EP	

## OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.)

/DD/	Flanders, D. C. et al., "Reactive Ion Etching of Indium Compounds using Iodine Containing Plasmas" J. Vac. Sci. Technology, B8 (6) Nov/Dec 1990, pp. 1990-1993.
/DD/	Liu, J. Q. et al., "Dry Etching Process in InP Gunn Device Technology Utilizing Inductively Coupled Plasma (ICP) System", 10th Intern. Conf. on Indium Phosphide and Related Materials, May 11-15, 1998, Tsukuba Japan, pp. 187-190.

EXAMINER

/Duy Vu Deo/ (09/18/2007)

DATE CONSIDERED

\* Copies of these references are not enclosed Pursuant to 37 CFR 1.98(d). (See accompanying IDS)

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